

NPN SILICON EPITAXIAL TWIN TRANSISTOR

UPA821TC

FEATURES

SMALL PACKAGE STYLE:

1.5 mm x 1.1 mm, 33% smaller than conventional SOT-363 package

• LOW HEIGHT PROFILE:

Just 0.55 mm high

• FLAT LEAD STYLE:

Reduced lead inductance improves electrical performance

• HIGH COLLECTOR CURRENT:

Ic MAX = 100 mA

ABSOLUTE MAXIMUM RATINGS¹ (TA = 25°C)

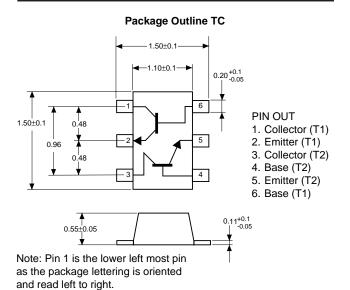
SYMBOLS	PARAMETERS	UNITS	RATINGS	
Vсво	Collector to Base Voltage	V	20	
VCEO	Collector to Emitter Voltage	V	12	
VEBO	Emitter to Base Voltage	V	3	
Ic	Collector Current	mA	100	
Рт	Total Power Dissipation 1 Die 2 Die	mW mW	TBD TBD	
TJ	Junction Temperature	°C	150	
Тѕтс	Storage Temperature	°C	-65 to +150	

Note: 1. Operation in excess of any one of these parameters may result in permanent damage.

DESCRIPTION

The UPA821TC contains two NE856 NPN high frequency silicon bipolar chips. NEC's new ultra small TC package is ideal for all portable wireless applications where reducing board space is a prime consideration. Each transistor chip is independently mounted and easily configured for oscillator buffer amplifier and other applications.

OUTLINE DIMENSIONS (Units in mm)



ELECTRICAL CHARACTERISTICS (TA = 25°C)

PART NUMBER PACKAGE OUTLINE			UPA821TC TC		
SYMBOLS	PARAMETERS AND CONDITIONS	UNITS	MIN	TYP	MAX
Ісво	Collector Cutoff Current at VcB = 10 V, IE = 0	μΑ			1.0
І ЕВО	Emitter Cutoff Current at VEB = 1 V, IC = 0	μΑ			1.0
hFE	DC Current Gain ¹ at VcE = 3 V, Ic = 7 mA		70		140
fτ	Gain Bandwidth at VcE = 3 V, Ic = 7 mA	GHz	3.0	4.5	
Cre	Feedback Capacitance ² at VcB = 3 V, IE = 0, f = 1 MHz	pF		0.7	1.5
S21E ²	Insertion Power Gain at VcE = 3 V, Ic =7 mA, f = 1 GHz	dB	7	9	
NF	Noise Figure at VcE = 3 V, Ic = 7 mA, f = 1 GHz	dB		1.2	2.5

Notes: 1. Pulsed measurement, pulse width \leq 350 μ s, duty cycle \leq 2 %.

- 2. Collector to base capacitance when measured with capacitance meter (automatic balanced bridge method), with emitter connected to guard pin of capacitance meter.
- 3. For tape and reel version, use part number UPA821TC-T1, 3K per reel.

California Eastern Laboratories